

HMA500 Holographic Mask Aligner



Specifications:

- Exposure wavelength : 364nm
- Exposure power : 4W max.
- Exposure field : 150mm x 150mm max.
- Resolution : 0.5 μ m
- Depth of focus : 1.2 μ m
- Alignment accuracy : down to 0.15 μ m (3 σ)
- Stitching accuracy : down to 0.15 μ m (3 σ)
- Substrate size : 400mm x 500mm max.
- Substrate and hologram loading : automatic
- Footprint (main unit): 210cm (L) x 135cm (D) x 200cm (H)